Supporting Information for

Understanding the Liquefaction in Halide Perovskites upon Methylamine Gas Exposure

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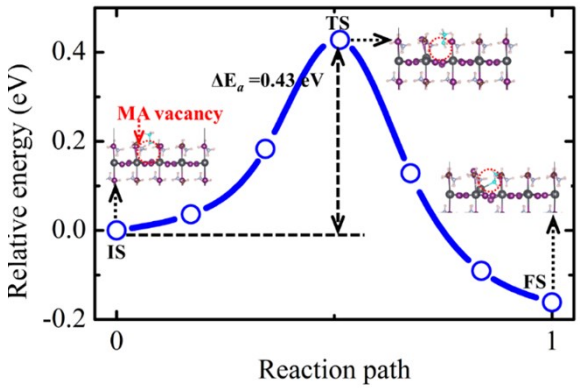

Fig. S1 Potential energy surface of methylamine gas molecule diffusion process, on the MA-vacancy perovskite surface.

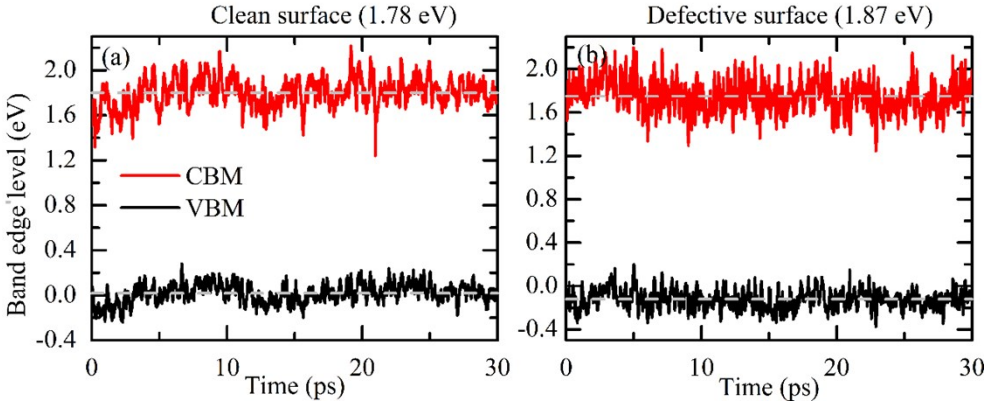

Fig. S2 Band edge level from AIMD simulation of MAI terminated with pristine-surface (left panel) and defect-surface (right panel). The gray dash line denotes the time averaged value of VBM and CBM.

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